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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re Application of:)
Robert Chau et al.)
Serial No.: 10/618,226)
Filed: July 11, 2003)
For: A METHOD FOR MAKING)
A SEMICONDUCTOR)
DEVICE HAVING A)
HIGH-K GATE DIELECTRIC)
Which is a Continuation of Application:)
Serial No.: 10/082,530)
Filed: February 22, 2002)
Examiner: J. Chen
Art Unit: 2813
Attorney Docket No: P12759C
Examiner: C. Lee
Art Unit: 2825

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

In response to the April 22, 2004 office action, applicants respectfully request the examiner to enter the proposed amendments, and to consider the following remarks along with the accompanying terminal disclaimer. In view of these amendments, and the submission of the terminal disclaimer, applicants respectfully request the examiner to allow the pending claims to issue.